

The Nobel Prize in Physics 1986 Ernst Ruska, Gerd Binnig, Heinrich Rohrer

The Nobel Prize in Physics 1986



Ernst Ruska



Gerd Binnig



Heinrich Rohrer

The Nobel Prize in Physics 1986 was divided, one half awarded to Ernst Ruska *"for his fundamental work in electron optics, and for the design of the first electron microscope"*, the other half jointly to Gerd Binnig and Heinrich Rohrer *"for their design of the scanning tunneling microscope"*. Source: Nobleprize.org

Scanning Probe Microscopy (SPM)

Scanning Tunneling Microscopy (STM)

Probe is scanned mechanically across the surface in a raster pattern while keeping track of the probe sample interaction

as a function of tip position Nobel Prize in Physics in 1986-Binning and Rohrer



Quantum Tunneling of electrons between two surfaces i.e. Tip and Sample, as they are brought close together that their electron clouds begin to overlap

Dr. Bilal Rasul Warraich, The University of Sargodha These lecture slides are primarily adapted from "Handbook of Deposition Technologies for Films and Coatings" by Peter M. Martin



Dr. Bilal Rasul Warraich, The University of Sargodha

- Tip of an atomically sharp electrode is positioned within a few nanometers of the surface and at low tip voltage bias probes the density of electronic states of the atoms comprising the surface by monitoring the tunneling current
- Negative Tip Bias: Current is measured through tunneling of electrons from the occupied states in the tip into the unoccupied states in the sample
- Positive Tip Bias: Electrons tunnel from occupied states in the sample into unoccupied states in the tip



Negative tip potential in which electrons tunnel from the tip into unoccupied states in the sample Positive tip in which electrons tunnel from occupied states in the sample into the tip

- Atomic resolution can be achieved because of distance dependence of tunneling current
- Tunneling Current $l\alpha e^{-2\kappa z}$, z=distance b/w tip and sample, $K^2 = 2m(V_B - E)/\hbar^2$, V_B =potential in the barrier, E=energy of the electronic state and($V_B - E$) is work function \approx 4-5 eV, so K=1 Å⁻¹ i.e. tunneling current drops by one order of magnitude for every Å of separation
- Optimum spatial resolution for an STM is approximately < 0.1 Å vertically and < 1 Å laterally
- Depending on the tip sharpness, surface roughness, electronic noise, and level of vibration in the system Dr. Bilal Rasul Warraich, The University of Sargodha

Auger Electron Spectroscopy (AES)

- Piezoelectric Actuators precisely control the tunneling junction
- Natural: Quartz, Topaz, Cane Sugar etc.
- Man-Made Crystals and Ceramics: $GaPO_4$, $BaTiO_3$, PbTiO₃, KNbO₃, Lead-Rirconium-Titanates (PZT) has sensitivity of the order of 1-5 Å/V
- Vibration free instrument using vibration isolation equipment



at/ionen-angewandte-physik/	nanobio/apparaturen/stm.ł	ntml					☆ 🥹	Ξ
ew Tab 📕 HBL 🚥 BBC - Homepag	ge 📄 International Mass S 👫	The American Socie	W Mass Spectrometry	Nuclear Instruments	🚪 Nano-Bio-Physics –	📋 Imported Fr	om IE	»
tarbeiter esseportal Chemische Physik Jmweltphysik / IMR Vano-Bio-Physik Mitarbeiter Publikationen Biomoleküle Cluster Dissoziative Elektronenanlagerung Ionen-Oberflächen-Stöße Apparaturen Interne Seiten nur für Mitarbeiter SASP Molekulare Systeme Complexe Systeme Atmosphärenchemie Experimentelle Plasmaphysik ichung dium nt chungsschwerpunkt Ionen- und maphysik / Angewandte Physik chungsschwerpunkt Advanced rials ntific Journals	Specifications Maximum size of images Resolution of the images Tip type: Sputter Source Type of Sputter-Target Diameter of Sputter-Targe Maximum power of sputter Distance to sample: Sputter gas: Pressure regime for sputt Typical experiments Growth of silicon films on Scanning tunneling lithog Scanning tunneling lithog Scanning tunneling spect Recent publications fro The publications are colled Diploma and PhD thesi Michaela Hager (PhD Michaela Hager (Dipl Radula Stijepovic (Di Stefan Jaksch (PhD -	17500nm atomic, if t Platinum/I Silicon 99. Silicon 9	x 17500nm ip is ok ridium for STM, Needle 999% s DC / 400Watts RF ¹ mbar t atabase. Loading my t ment	Sensor with piezo for AFI	М			
	It/ionen-angewandte-physik/ w Tab HBL BBC - Homepage arbeiter Isseportal Chemische Physik Imweltphysik / IMR Iano-Bio-Physik Mitarbeiter Publikationen Biomoleküle Cluster Dissoziative Elektronenanlagerung Ionen-Oberflächen-Stöße Apparaturen Interne Seiten nur für Mitarbeiter SASP Iolekulare Systeme Complexe Systeme tmosphärenchemie Experimentelle Plasmaphysik chung lium It chungsschwerpunkt Ionen- und naphysik / Angewandte Physik chungsschwerpunkt Advanced rials htific Journals	at/ionen-angewandte-physik/nanobio/apparaturen/stm.l w Tab HBL BBC - Homepage International Mass S Image: Seportal Seportation Seportation of the Images Resolution of the Images Resolution of the Images Tip type: Biomoleküle Specifications Cluster Dissoziative Seportal Seportal Seportal Seportal Seportal Seportation Second S	tt/ionen-angewandte-physik/nanobio/apparaturen/stm.html w Tab MBL 000 BBC - Homepage I International Mass S International	tt/ionen-angewandte-physik/nanobio/apparaturen/stm.html w Tab ■ HBL @ BBC - Homepage ♪ International Mass S The American Socie Mass Spectrometry arbeiter sseportal themische Physik mweltphysik / IMR ano-Bio-Physik Mitarbeiter Publikationen Biomoleküle Cluster Dissoziative Elektronenanlagerung Disputer Surce Type of Sputter-Target: Silicon 99.999% Diameter of Sputter-Target: Silicon 99.999% Diameter of Sputter-Target: Silicon 99.999% Diameter of Sputter-Target: Silicon 99.999% Distance to sample: 33cm Sputter gas: Argon Pressure regime for sputtering: 10 ⁻² - 10 ⁻¹ mbar Typical experiments Growth of silicon films on HOPG Scanning tunneling spectroscopy tt Recent publications from this experiment The publications are collected in the NanoBioDatabase. Loading my th htmasschwerpunkt Ionen- und machsik / Anaewandte Physik thinabeale Hager (PhD - ongoing) Nichaela Hager (Diploma - 2009) Stefan Jaksch (PhD - 2009) Stefan Jaksch (PhD - 2009) Stefan Jaksch (Diploma - 2005)	tt/ionen-angewandte-physik/nanobio/apparaturen/stm.html w Tab HBL III BBC - Homepage international Mass S international Mas	t/fonen-angewandte-physik/hanobio/apparaturen/stm.html w Tak BL 100 BBC - Homepage International Mass Su 100 The American Socie 100 Mass Spectrometry Insuccient Instruments Insuccient Instruments	t/ionen-angewandte-physik/nanobio/apparaturen/stm.html International Mass S. International Mass S.	thionen-angewandte-physik/nanobio/apparaturen/stm.html Image: Construction of the mage of the material socie. Image: Construction of the mage of the material socie. Image: Construction of the mage of the material socie. Image: Construction of the mage

6

(

(

Dr. Bilal Rasul Warraich, The University of Sargodha

How the images came to life...



Source: IBM

Dr. Bilal Rasul Warraich, The University of Sargodha

How the images came to life...

1. A tip is scanned over a surface at a distance of a few atomic diameters in a point-by-point and line-by-line fashion. At each point the tunneling current between the tip and the surface is measured. The tunneling current decreases exponentially with increasing distance and thus, through the use of a feedback loop, the vertical position of the tip can be adjusted to a constant distance from the surface.

2. The amount of these adjustments is recorded and defines a grid of values which can be displayed as a grayscale image.

3. Instead of assigning the values to a color we can also use them to deform the grid in the direction perpendicular to the surface.

4. Now we can bring back the grayscale and paint each square according to an average of the four defining grid points.

5. Now we paint the whole surface uniformly gray and switch on the lights.

6. We can use several lights at different positions and with different colors.

7. Instead of painting the surface just gray we can use a color palette and paint it according to height.

8. Or we choose the color according to another surface property, let's say curvature. *Source: IBM*

 Constant Current Mode: Voltage bias is applied across the tunnel barrier, the tunneling current is measured and kept constant through computercontrolled feedback which controls the separation distance using the vertical piezoelectric actuator,

 Constant Height Mode: Tip is maintained at a fixed height above the average surface and the topography is reflected in the variations in tunneling current

STM measures not sample topography, but the local density of states of the sample



Dr. Bilal Rasul Warraich, The University of Sargodha

 Adsorbates on a sample surface, which have different electronic density of states from that of a uniform substrate, and which alter the surface topography of the sample, will change the tunneling current passing through the tip as it passes over it. This provides contrast in an STM image, allowing this technique to probe the shape, conformation, and distribution of atoms or molecules residing on the surface of an atomically flat conducting substrate

Scanning Tunneling Spectroscopy (STS)

- Wentzel-Kramers-Brilloun(WKB) approximation of tunneling current
- High frequency voltage modulator is added to tip bias $I = \int g(F) g(eV + F) T(F + eV) dF$

$$I = \int \rho_{\rm t}(E) \,\rho_{\rm s}(eV + E) \,T(E, eV) dE$$

 $\rho_t(E)$ =density of electronic states at energy E

- $\rho_s(eV+E)$ =density of electronic states in the biased sample
- T(E,eV)=Tunneling Transmission Probability

• Strengths:

- Subatomic vertical resolution
- High lateral spatial resolution (atomic in some cases)
- Operates in ambient, vacuum or aqueous conditions
- Little sample preparation necessary (except UHV STM)
- Limitations:
- Samples limited to conductors or semiconductors
- Tip artifacts are possible
- Not amenable for samples with excessive roughness